Testing and Analysis of Piezoresistive Signals from SiC MEMS Accelerometers with Application to Penetration Fuzing



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- Research Team
- Objectives
- Background
- Design and Fabrication
- Evaluation
- Results
- Accomplishments
- Future Work
- Conclusion





- **AFRL Munitions Directorate** 
  - Fuzes Branch: Dr. Alain Beliveau, Dr. Alex Cash,
     1Lt. Ken Bradley, Mr. Jason Foley
  - Dr. Scott Roberson (now at SAF/AQ)
- NASA Glenn Research Center
  - Dr. Robert Okojie
- Cornell University
  - Prof. Kevin Kornegay, Dr. Andy Atwell (now at IDA)





- Develop a scientific understanding of...
  - Stress distribution and concentration
  - Microstructural transformation
- ... for devices functioning in *harsh environments* to better predict failure and improve sensitivity

- High Stress/Pressure
  - High Temperature (>250°C)
  - High Power/Voltage (switches, μ–wave)
  - Corrosion
  - **Erosion and Wear**
  - Radiation
  - **Shock and Vibration**



# Background



SiC selected as material...

- Wide Bandgap 2 x Silicon
- High Thermal Conductivity
- Polytypic (3C, 6H, ...)
- Chemically Inert
- Superior Mechanical Properties over Si
  - 3 x Yield Strength
  - 3.5 x Young's Modulus
    - Similar strains... due to greater max yield strength







**Device Concept:** 

Suspended membrane with piezoresistive elements (mesas)

- Epilayer deposition
  - PECVD
- Bulk micromachining of silicon carbide
  - Reactive Ion Etch (Anisotropic)



Source: K. Kornegay, Cornell U.



# **Design and Fabrication**



- Device series:
  - 1. Cornell Types 1-3
  - 2. NASA Generation 1
  - 3. NASA Generation 2



2. Optical micrograph of Gen 1 NASA sensor (no boss)



1. SEM micrographs of the Cornell designs



3. SEM micrograph of Gen 2 NASA sensor (with boss)

### Sample SiC MEMS Layout (NASA Generation 1)







### Sample SiC MEMS Operation (NASA Generation 1)



Wheatstone Bridge





### **Evaluation**



- Microcharacterization
  - SEM, XRD, etc.
- Stress Evaluation (Accelerometers)
  - Steady State (Centrifuge):
     Calibration
  - Dynamic (Shock Machine): Real Time Data
  - Temperature: Internal Stress Development
- Develop feedback for future designs, understanding of fundamental mechanisms





### **Evaluation**





# Very High-g (VHG) Machine

- Dynamic Test to Failure
- Determine Real-Time Stress from Centrifuge Data
- Separation of Design and Material Properties Failures
- Serves as Baseline for Empirical Modeling
- VHG allows determination of failure due to mechanical stress and resonance frequency phenomenon









### Baseline: Endevco 7270A

- Peak mag up to 200k x g
- Survivable







### Cornell University Types 1-3 Simple membrane devices









- SiC MEMS device matched output of Industry
   Standard
   Endevco 7270
   Accelerometer
   within 5% up to
   20k x g
- Very low sensitivity (75 nV/g) compared to Endevco (4 μV/g)

### Black – Endevco 7270 Gray – SiC MEMS (CU1)









#### **NASA Generation 1**

#### Innovative design with boss for increased sensitivity



A SEM micrograph of the backside deep reactive ion etch for the NASA bossed sensor.







- NASA SiC MEMS matched output of Endevco 7270 to 8k x g
- Survived to 80k x g
- Sensitivity:
   0.125 μV/g

### Blue– Endevco 7270 Red – SiC MEMS (NASA1)









- Strong "cross axis" sensitivity or cross axis resonance mode was observed ~9k x g
- Cross axis sensitivity increased with increasing axial g's, dominating signal
- New design: no boss

#### Blue– Endevco 7270 Red – SiC MEMS (NASA1)









#### **NASA Generation 2**

#### No boss for decreased cross-axis sensitivity





### **Results**



- Matched output of Endevco 7270 until a dominating resonance mode around 1.3 msec
- Output recovered around 1.6 msec and matched that of the Endevco 7270

#### Blue – Endevco 7270 Red – SiC MEMS (NASA2)









### Repeatable results

 Matched the Endevco 7270 first peak intensity very well

#### Blue – Endevco 7270 Red – SiC MEMS (NASA2)







- Three Generations of SiC MEMS have been modeled, fabricated and evaluated for Stress development
  - Cornell University Types 1-3
    - Simple Round Membrane
      - Easy to model, fabricate and interpret scientific data
  - NASA Glen Research Center Generation 1
    - Complex designs for Improved Sensitivity
      - More Difficult to Interpret Data but more sensitive
  - NASA Glen Research Center Generation 2
    - Redesigned to avoid problems from gen 1





- Established MOA with NASA Glenn Research center for Long-Term, Joint SiC MEMS Collaboration
- First Published Peer Reviewed Journal Article on SiC MEMS: *IEEE Journal of Sensors and Actuators A 104, 2003 (11-18)*
- First Conference Paper on Operating SiC MEMS: Jan 02 IEEE Conference, Las Vegas, NV
- PhD Dissertation at Cornell University by Dr. Andy Atwell: Modeling, Simulation, and Fabrications of SiC MEMS

- Funded by AFOSR and NASA Glenn





- Material effects of thermomechanical cycling
  - Thermal cycling coupled with mechanical cycling
- Improving device function and reliability
  - Increasing axial sensitivity
  - Decreasing cross-axial sensitivity
  - Reducing bias
- Enhanced "nondestructive" evaluation *in situ* 
  - Velocity interferometer (VISAR)







- Investigating microstructural changes
  - Defects
  - Hysteresis
  - Phase changes
- Initial shock tests of 1st generation NASA GRC accelerometers
- 2nd generation NASA GRC accelerometers (4Q04)







- SiC MEMS that function in harsh environments have been demonstrated
  - Fabricated (Cornell, NASA Glenn)
  - Tested (AFRL/MN)
- Improvements necessary to achieve desired functionality
  - Problems with cable noise, sensitivity, cross-axis
- Continuing investigation by focusing on fundamental mechanisms will enhance effort

### **End of Presentation**

### **Backup Slides**





 Atwell, Andrew R., Okojie, Robert S., Kornegay, Kevin T., Roberson, Scott L., and Beliveau, Alain, 2003, "Simulation, fabrication and testing of bulk micromachined 6H-SiC high-g piezoresistive accelerometers," Sensors and Actuators A, 104, pp. 22-18.



Atwell et al, 2003, Sens Act A, 104, pp 11-18.pdf

 Okojie, Robert S., Atwell, Andrew R., Kornegay, Kevin T., Roberson, Scott L., and Beliveau, Alain, 2002, "Design Considerations for Bulk Micromachined 6H-SiC High-g Piezoresistive Accelerometers," Tech. Digest 15th IEEE Intl. Conf. on MEMS, Las Vegas, Nevada (Jan. 20-24, 2002), pp. 618-622.



Okojie et al, 2002, Tech Dig 15th IEEE Conf MEMS, pp 618-622.pdf

### **SiC: Mechanical Properties**

Property Table

Percentages in parentheses denote estimated combined relative standard uncertainties of the property values. For example, 3.0(5%) is equivalent to 3.0 + - 0.15. Property values in parentheses are extrapolated values.

Property [unit]	20 °C	500 °C	1000 °C	1200 °C	1400 °C	1500 °C
Bulk Modulus [GPa]	203 (3%)	 197	 191	 188	 186	184
Creep Rate [10 <sup>-9</sup> s <sup>-1</sup> ] at 300 MPa	0	0	0	0.004(17%)	0.27	1.6
Density [g/cm <sup>3</sup> ]	3.16(1%)	3.14	3.11	3.10	3.09	3.08
Elastic Modulus [GPa]	415(3%)	404	392	387	383	380
Flexural Strength [MPa]	359(15%)	359	397	437	446	446
Fracture Toughness [MPa m <sup>1/2</sup> ]	3.1(10%)	3.1	3.1	3.1	3.1	3.1
Friction Coefficient [], 0.2 m/s,5 N	0.7(21%)	0.4	0.4			
Hardness (Vickers, 1 kg) [GPa]	32(15%)	17	8.9	(6.9)	(5.3)	(4.6)
Lattice Parameter a(polytype 6H) [Å]	3.0815(0.01%)	3.0874	3.0950	(3.0984)	(3.1021)	(3.1040)
Lattice parameter c(polytype 6H) [Å]	15.117(0.02%)	15.144	15.179	(15.194)	(15.210)	(15.218)
Poisson's Ratio []	0.16(25%)	0.159	0.157	0.157	0.156	0.156
Shear Modulus [GPa]	179(3%)	174	169	167	166	165
Sound Velocity, longitudinal [km/s].	11.82(2%)	11.69	11.57	11.52	11.47	11.44
Sound Velocity, shear [km/s]	7.52(2%)	7.45	7.38	7.35	7.32	7.31
Specific Heat [J/kg·K]	715(5%)	1086	1240	1282	1318	1336
Tensile Strength [MPa]	250(6%)	250	250	250	250	250
Thermal Conductivity [W/m·K]	114(8%)	55.1	35.7	31.3	27.8	26.3
Thermal Diffusivity [cm²/s]	0.50(12%)	0.16	0.092	0.079	0.068	0.064
Thermal Expansion from 0 °C [10 <sup>-6</sup> K <sup>-1</sup> ]	1.1(10%)	4.4	5.0	5.2	5.4	5.5
Wear Coefficient(Log10)[],0.2 m/s,5 N	-4.0(5%)	-3.6	-3.6			
Weibull Modulus []	11(27%)	11	11	11	11	11

### **SiC: Electrical Properties**

PROPERTY	3C-SiC	6H-SiC
Bandgap (eV) at 300 K	2.3	2.9
Maximum operating temperature (°C) 300	873	873
Melting point (°C)	Sublimes >1800	Sublimes >1800
Physical stability	Excellent	Excellent
Electron mobility (cm²/V-s)	1000	600
Hole mobility (cm²/V-s)	40	40
Breakdown field, E <sub>b</sub> (10 <sup>-6</sup>	V/cm) 4	4
Thermal conductivity, σ <sub>T</sub> (W/cm-°C)	5	5
Sat. elect. drift velocity, v <sub>sat</sub> (10 <sup>7</sup> cm/ s)	2.5	2.5
Dielectric constant, $\epsilon$	9.7	9.7

Source: V. Shields, JPL (NASA)

#### Accelerometer Circuit Configuration



The above configuration makes the Wheatstone Bridge an open one. It allows each resistor element BC, CD, DE, and EA to be measured independently. When 2/3 is connected together, the bridge is closed. To be consistent, the power supply  $Vin_1$  and  $Vin_2$  should be connected at pin 7 and 2/3, respectively. The output  $Vo_1$  and  $Vo_2$  should be tapped at pin 6 and 1, respectively.



# SILICON CARBIDE MEMS



TYPE 1 TYPE 2 TYPE 3 TYPE 3 TYPE 1 TYPE 2 TYPE 3 TYPE 3 TY	<b>OBJECTIVE</b> • UNDERSTAND STRESS DEVELOPMENT AND DETERMINE FUNDAMENTAL FAILURE MECHANISMS OF SILICON CARBIDE MEMS ACCELEROMETERS UNDER HIGH SHOCK AND HIGH TEMPERATURE LOADING TO ENABLE USE IN HARSH ENVIRONMENTS
PAST ACCOMPLISHMENTS	<b>TECHNICAL MILESTONES</b>
<ul> <li>FIRST GENERATION ACCELEROMETERS FABRICATED AND EVALUATED - DATA TO BE PUBLISHED</li> </ul>	<ul> <li>INITIAL FEASIBILITY STUDY IN SIC MEMS 2Q99</li> <li>INITIAL DESIGN OF SIC MEMS</li> </ul>
THREE TYPES OF DEVICES WERE DESIGNED AND FABRICATED TO ALLOW FOR ACCURATE DETERMINATION OF STRESSES	ACCELEROMETER 4Q99 INITIAL FABRICATION OF SIC MEMS 2Q00
<ul> <li>SECOND GENERATION DEVICES HAVE BEEN DESIGNED AND EVALUATED</li> </ul>	EVALUATION OF FIRST GENERATION     DEVICES 3Q00
	OPR: DR.SCOTT ROBERSON, DSN 872-2006, X257 PA 00-395